07 September 2022

Productizing a PIC: from Design IP to Scalable Testing





About us

A Hitachi Group Company

- VLC Photonics offers Photonic Integrated Circuit (PIC) development services, focused on design and testing.
- **C** Company founded in 2011.
- C Offices and clean-room labs in Valencia Technological Campus (Spain).
- 21 members of extensive academic and industrial experience, and keep growing.
- **E** 13+ years in the field of integrated optics and Photonics.
- Part of Hitachi High-Tech group since 2020.

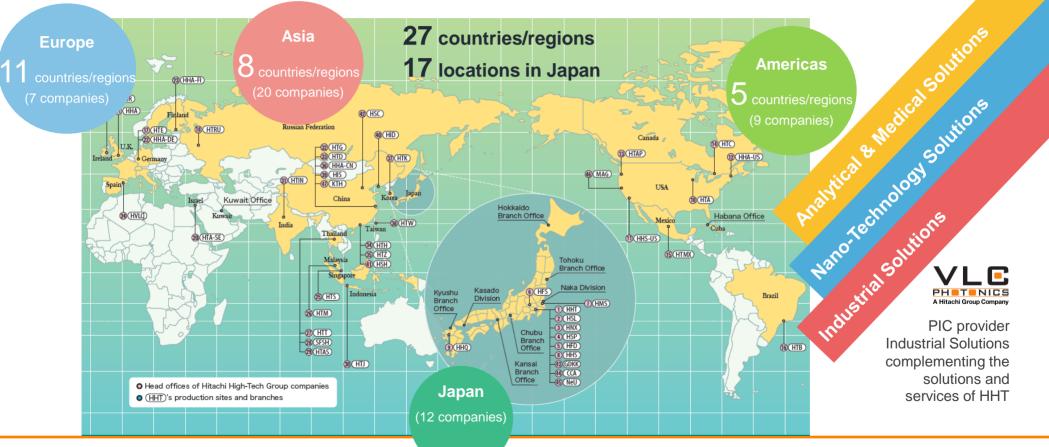




About us (II)

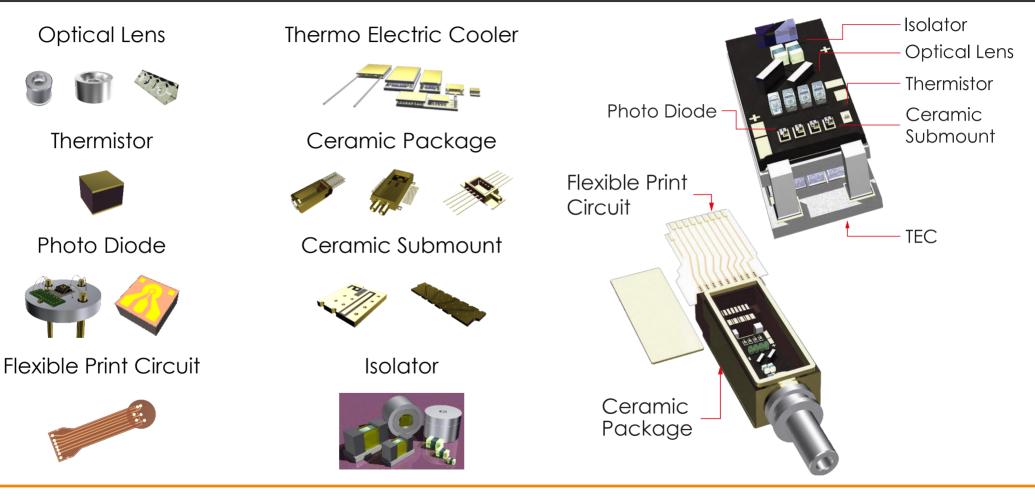


@Hitachi High-Tech Corporation



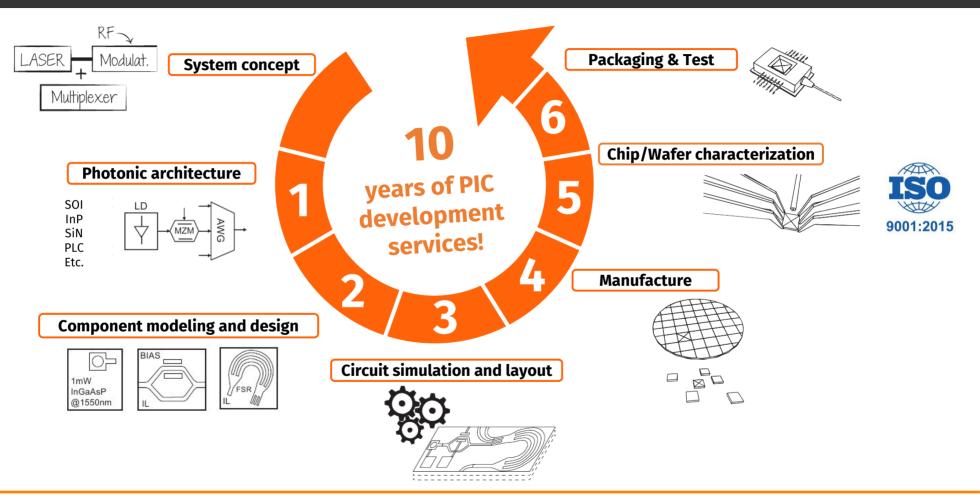
HHT optical components supply





Our solutions





Semiconductor Design IP



- It helps to speed up chip development and lower risk and cost, by licensing validated designs that can be embedded into more complex circuits.
- Semiconductor design IP has been well stablished in the last two decades:
 - +3.6B\$ market in 2018
 - Fabless companies
 - ARM (45%) and Synopsys (17%) dominate market share
 - Most of it is digital electronics design
- Main categories are:
 - <u>Processor:</u> CPU, DSP and GPU
 - <u>Interface:</u> protocol-based function like USB, PCI Express, Ethernet, MIPI, SATA, DP, but also Die-to-Die (D2D) interface and memory controller.
 - <u>Other Physical:</u> SRAM and other memory compiler, physical library, Analog & Mixed-Signal, Wireless Interface, etc...

Differences with photonic design IP



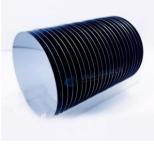
• Wafer fabs:

- Electronic foundry landscape dominated by 5 main players: TSMC, UMC, SMIC, Samsung, GF. Well stablished IP ecosystem and framework.
- Photonics foundries are less and smaller. No IP licensing framework.

• Cost of design IP validation:

- >250M wafers/year in electronics, very high yields.
- Lot's of R&D, NRE and legal expenses required in photonics compared to the possible market, given the lower TRL.
- Market demand:
 - Global electronics market is several orders of magnitude larger than photonics one.
 - Most of the photonic product developments are being done by start-ups now.





Current photonic design IP status



- Most of the players have developed a full fab process, or custom module on top of a generic foundry process.
 - Not so fabless anymore, significant CAPEX tied to a fab (~IDM's)
 - Differentiation not in design but in front-end/back-end
 - Usually offer optical engines = validated PICs
 - No open access libraries or PDKs

• Lack of standards:

- Many new emerging applications: quantum, LIDAR, AI, AR...
- Design IP is still very customized, limiting its potential customer base
- Risk of development obsolescence in a quickly evolving field



- Lots of interesting patented or published designs by academics or small start-ups lack real-world applicability.
- Validation for a guaranteed commercial offering still very challenging.



- It is still critical to do extensive component / circuit characterization when validating PIC designs towards production.
 - Optical alignment
 - Opto-electronic measurement
 - Processing and Root cause analysis
- When moving to PIC volume production, scalability becomes an issue:
 - Functional circuit testing is still required beyond fab metrology and PCM
 - Need fast and low cost Wafer/KGD sorting and packaging
 - Parallelization is hard, significant CAPEX and setup time required

Advantages of outsourcing the photonic back-end

E Infrastructure investment:

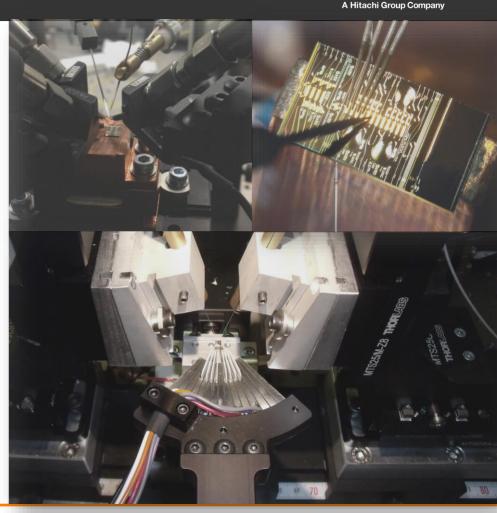
- Cleanroom lab
- Opto-electronic probing stations
- High-end instrumentation
- Consumable stocking
- Redundancy for non-stop operations

E Engineering expertise:

- Automation
- Photonics
- Big data processing and analysis
- Quality certifications & calibrations

E Timing:

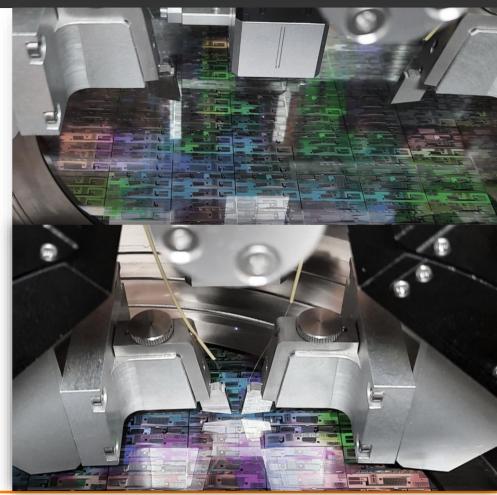
- Procurement
- Installation and configuration
- Hiring and training



Focus on characterization & test

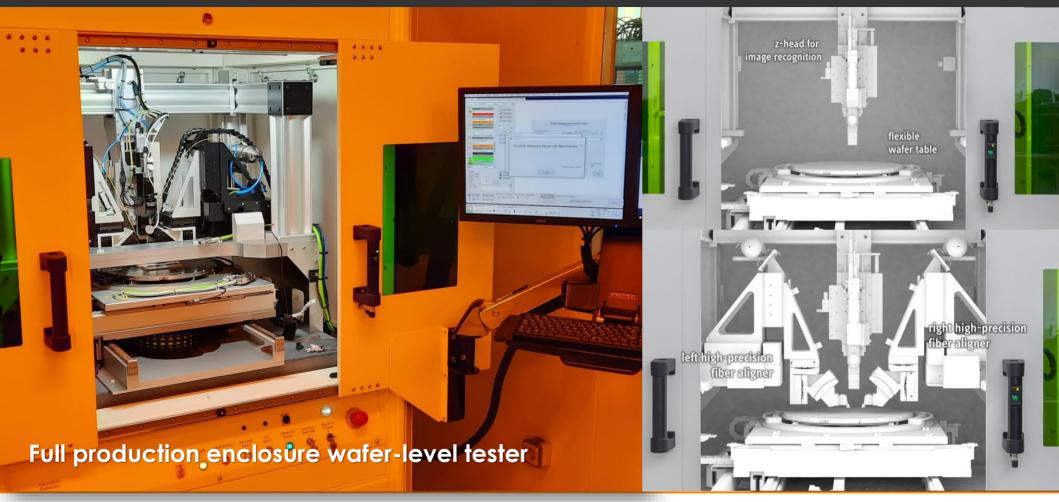


- Close design loop from fabricated to measured devices with big data, allowing for statistical parameter modelling.
- Provide feedback to customers & foundries for process yield improvement, to accelerate product development and volume ramp up.
- Automate identification of KGD to sort dies/wafers in production, and towards packaging.



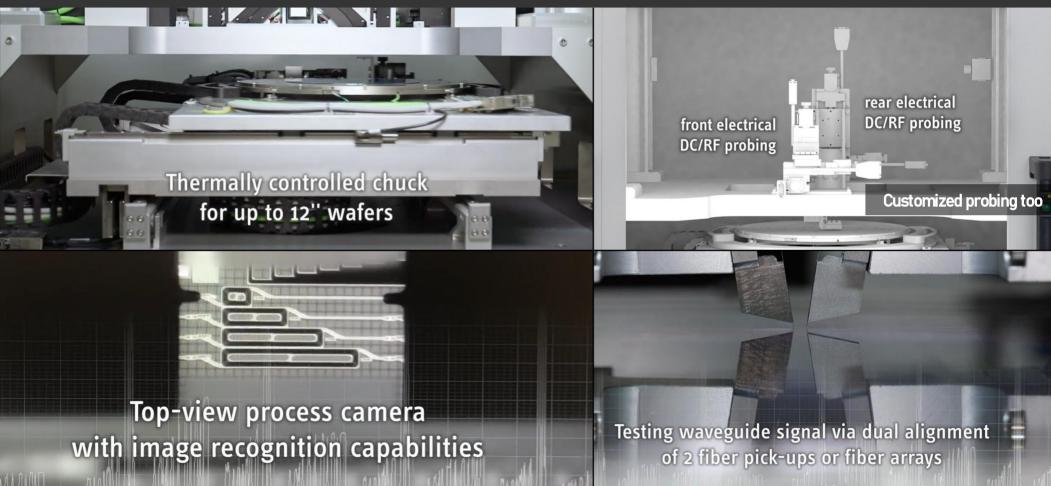
Automated Wafer-level Photonic tester





Automated Wafer-level Photonic tester





Automated Wafer-level Photonic tester

888



<4s optical alignment 0.1/0.4 dB repeatability Depends on fab process and grating coupler design

Die level testing possible

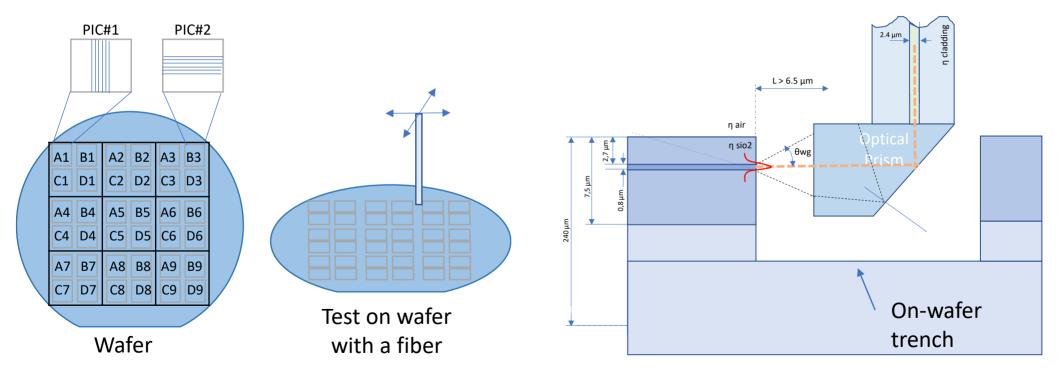
Fully automated data collection and processing

Tool and setup scale-up options

Edge coupling WLT

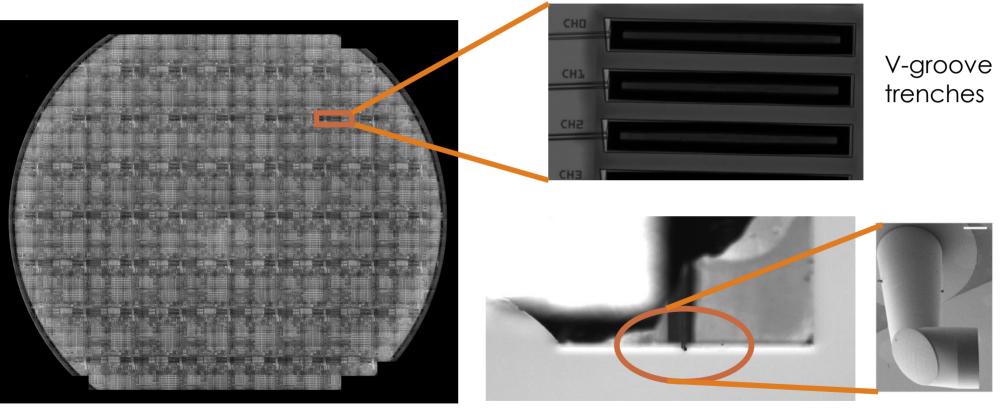


C Tool adapted for optical edge coupling via deep-etch wafer trenches.



Edge coupling WLT (II)





3D printed micro-lens

MFD 2.3-10.4 µm

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Examples of previous projects:

DUT	Structures	Measurements
Six 6" wafers, >300 dies	>5k	~50k
Two 8" wafers >1800 dies	>14.5k	~58k
>50 dies	>140	>31k

- Fast probing and trace acquisition times are essential when scaling up.
- Smart characterization plan needed for insightful but time-practical test campaign.

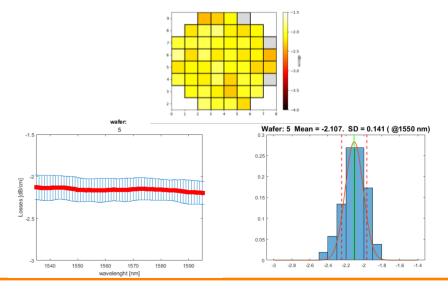


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- Repeatability of bare die measurements with manual alignment is poor (>0.5 dB).
- WLT ensures that alignment and trace acquisition are done automatically with minimal variations (mechanical, thermal etc.)



RF testing key for next-gen datacom PICs





- Lightwave Component Analyser (LCA) for parametric testing of devices like high speed modulators in datacom transceivers.
 - 110 GHz Turn-Key Test System for Optical RX and TX
 - Suitable for die and wafer level testing
 - Return to zero and nonreturn-to-zero (RZ / NRZ) and pulse amplitude modulation (PAM) formats
 - S-parameter testing over the full 1260 nm to 1620 nm range
 - Available for both automated die and wafer level testing





 To develop design IP or productize any PIC, characterization and test are significant cost & time bottlenecks.

 To produce state-of-the-art PICs in volumen, any photonic back-end technology needs to be scalable from the start.

3. VLC/Hitachi High-tech have the resources and expertise to support PIC developments all the way to production.

Thank you for your attention!



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